

## Cocktail precursor FER-1

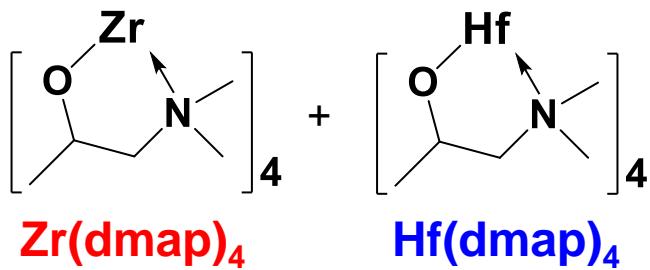


Fig. 1 Chemical structure of FER-1

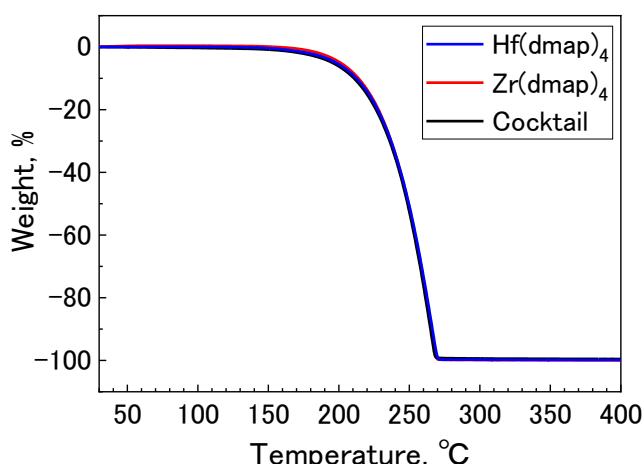


Fig. 3 TGA curve of  $\text{Hf}(\text{damp})_4$ ,  $\text{Zr}(\text{dmap})_4$ , and the cocktail precursor at 760 Torr.

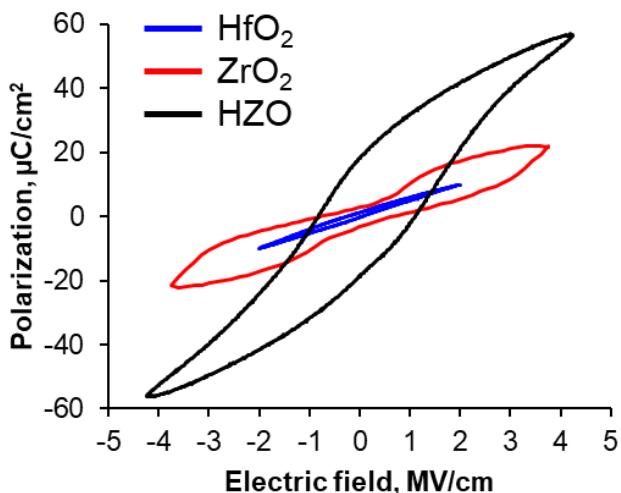


Fig. 5 Polarization versus electric field ( $P$ - $E$ ) curves for the  $\text{HfO}_2$ ,  $\text{ZrO}_2$ , and HZO films.

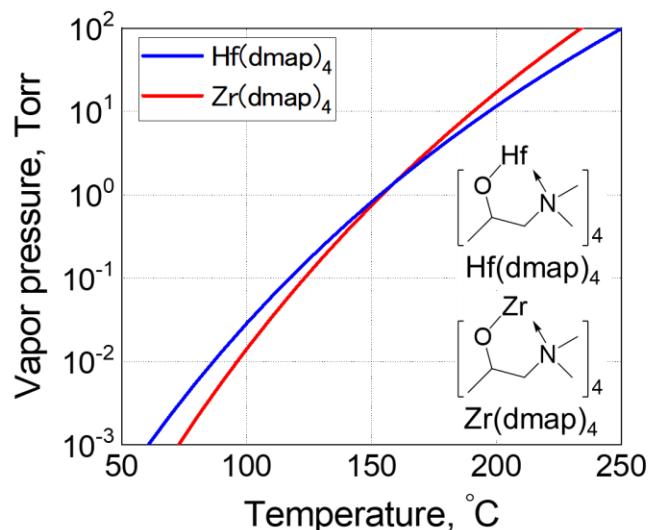


Fig. 2 Variation of the vapor pressure of  $\text{Hf}(\text{dmap})_4$  and  $\text{Zr}(\text{dmap})_4$  as a function of temperature.

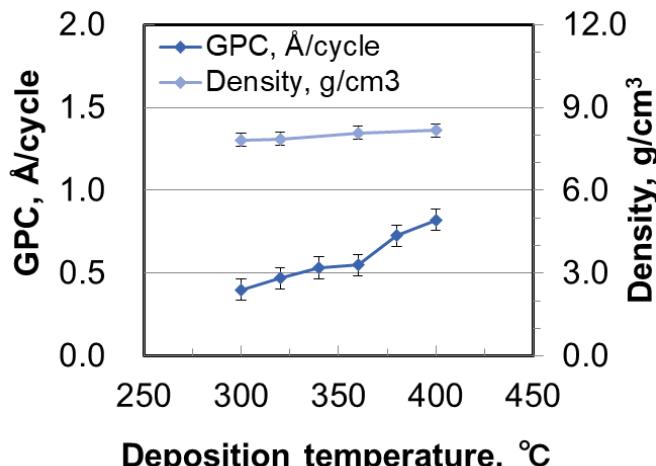


Fig. 4 Temperature dependence of the growth rate and density of the cocktail precursor using  $\text{O}_3$  as a co-reactant.

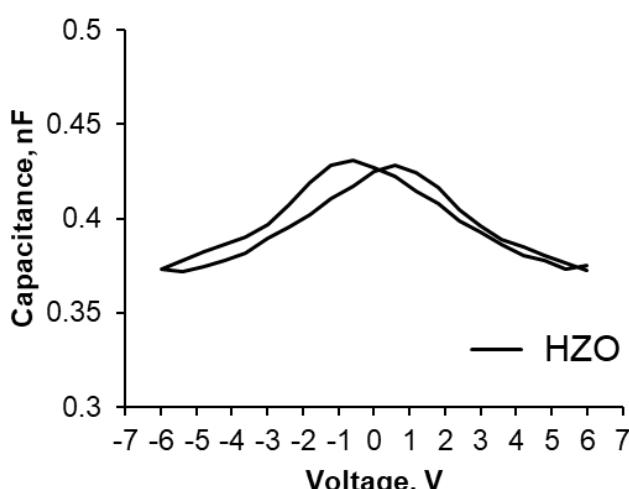


Fig. 6 C–V curves of the  $\text{TiN}/\text{HZO}/\text{TiN}/\text{p-Si}$  MIM capacitor at a frequency of 100 kHz.